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COST IN U.S. DOLLARS

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ENTRY

SESSION

FULL ESTIMATED COST

0.21

0.21

s Kirchmeyer, Stephan/in

1 FILES SEARCHED...

L1 54 KIRCHMEYER, STEPHAN/IN

=> s 11 and polythiophene#

L2 6 L1 AND POLYTHIOPHENE#

=> d 12 1-6

L2 ANSWER 1 OF 6 EUROPATFULL COPYRIGHT 2003 WILA

Full  
Text

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 1215224 EUROPATFULL ED 20020626 EW 200225 FS OS

TIEN Polythiophene.

TIDE Polythiophene.

TIFR Polythiophene.

IN Kirchmeyer, Stephan, Dr., Ernst-Ludwig-Kirchner-Strasse 45, 51375

Leverkusen, DE;

Wussow, Klaus, Dr., Oberlinweg 8, 57250 Netphen, DE;

Jonas, Friedrich, Dr., Krugenofen 15, 52066 Aachen, DE;

Elschner, Andreas, Dr., Lederstrasse 6, 45479 Muelheim, DE

PA BAYER AG, 51368 Leverkusen, DE

SO Wila-EPZ-2002-H25-T1a

DS R AT; R BE; R CH; R CY; R DE; R DK; R ES; R FI; R FR; R GB; R GR; R IE;

R IT; R LI; R LU; R MC; R NL; R PT; R SE; R TR; R AL; R LT; R LV; R MK;

R RO; R SI

PIT EPAL EUROPÄISCHE PATENTANMELDUNG

PI EP 1215224 Al 20020619

OD 20020619

AI EP 2001-126452 20011109

PRAI DE 2000-10058116 20001122

IC ICM C08G061-12

ICS H01B001-12

L2 ANSWER 2 OF 6 PCTFULL COPYRIGHT 2003 Univentio

Full  
Text

AN 2002072660 PCTFULL ED 20020927 EW 200238

TIEN NOVEL POLYTHIOPHENE DISPERSIONS

TIFR NOUVELLES DISPERSIONS DE POLYTHIOPHENE

TIDE NEUE POLYTHIOPHEN-DISPERSIONEN

IN JONAS, Friedrich; KIRCHMEYER, Stephan

PA BAYER AKTIENGESSELLSCHAFT, for all designates States except US; JONAS,

Friedrich, for US only; KIRCHMEYER, Stephan, for US only

AG BAYER AKTIENGESSELLSCHAFT

LAF German

LA German

DT Patent  
 PI WO 2002072660 A1 20020919  
 DS AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ DE DK DM DZ  
 EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE KG KP KR KZ LC LK LR  
 LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ OM PH PL PT RO RU SD SE SG SI  
 SK SL TJ TM TN TR TT TZ UA UG US UZ VN YU ZA ZM ZW GH GM KE LS MW MZ SD  
 SL SZ TZ UG ZM ZW AM AZ BY KG KZ MD RU TJ TM AT BE CH CY DE DK ES FI FR  
 GB GR IE IT LU MC NL PT SE TR BF BJ CF CG CI CM GA GN GQ GW ML MR NE SN  
 TD TG  
 AI WO 2002-EP2066 A 20020227  
 PRAI DE 2001-101 11 790.6 20010312  
 ICM C08G061-12  
 ICS H01B001-12

L2 ANSWER 3 OF 6 PCTFULL COPYRIGHT 2003 Univentio

Full  
Text

AN 2002042352 PCTFULL ED 20020610 EW 200222  
 TIEN DISPERSIBLE POLYMER POWDERS  
 TIFR POUDRES POLYMERES DISPERSIBLES  
 TIDE DISPERGIERBARE POLYMERPULVER  
 IN WESSLING, Bernhard; **KIRCHMEYER, Stephan**; GEHRMANN, Dietrich  
 PA BAYER AKTIENGESELLSCHAFT, for all designates States except US; WESSLING,  
 Bernhard, for US only; KIRCHMEYER, Stephan, for US only; GEHRMANN,  
 Dietrich, for US only  
 AG BAYER AKTIENGESELLSCHAFT  
 LAF German  
 LA German  
 DT Patent  
 PI WO 2002042352 A2 20020530  
 DS AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ DE DK DM DZ  
 EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE KG KP KR KZ LC LK LR  
 LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ OM PH PL PT RO RU SD SE SG SI  
 SK SL TJ TM TR TT TZ UA UG US UZ VN YU ZA ZM ZW GH GM KE LS MW MZ SD SL  
 SZ TZ UG ZM ZW AM AZ BY KG KZ MD RU TJ TM AT BE CH CY DE DK ES FI FR GB  
 GR IE IT LU MC NL PT SE TR BF BJ CF CG CI CM GA GN GQ GW ML MR NE SN TD  
 TG  
 AI WO 2001-EP13390 A 20011120  
 PRAI DE 2000-100 58 118.8 20001122  
 DE 2001-101 55 238.6 20011109  
 ICM C08G061-12  
 ICS C08L065-00; C09D005-24; H01B001-12

L2 ANSWER 4 OF 6 PCTFULL COPYRIGHT 2003 Univentio

Full  
Text

AN 2000045625 PCTFULL ED 20020515  
 TIEN METHOD FOR THE DIRECT ELECTROPLATING OF THROUGH-HOLES IN PRINTED CIRCUIT  
 BOARDS  
 TIFR PROCEDE DE METALLISATION GALVANIQUE DIRECTE DES TROUS DE CARTES DE  
 CIRCUITS  
 IN **KIRCHMEYER, Stephan**; JONAS, Friedrich  
 PA BAYER AKTIENGESELLSCHAFT; KIRCHMEYER, Stephan; JONAS, Friedrich  
 LA German  
 DT Patent  
 PI WO 2000045625 A2 20000803  
 DS AE AL AM AT AU AZ BA BB BG BR BY CA CH CN CR CU CZ DE DK DM EE ES FI GB  
 GD GE GH GM HR HU ID IL IN IS JP KE KG KP KR KZ LC LK LR LS LT LU LV MA  
 MD MG MK MN MW MX NO NZ PL PT RO RU SD SE SG SI SK SL TJ TM TR TT TZ UA  
 UG US UZ VN YU ZA ZW GH GM KE LS MW SD SL SZ TZ UG ZW AM AZ BY KG KZ MD  
 RU TJ TM AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE BF BJ CF  
 CG CI CM GA GN GW ML MR NE SN TD TG  
 AI WO 2000-EP256 A 20000114  
 PRAI DE 1999-199 03 108.8 19990127

ICM H05K003-00

L2 ANSWER 5 OF 6 USPATFULL

Full Text	Citing References
AN	2002:308451 USPATFULL
TI	Novel <b>polythiophene</b> dispersions
IN	Jonas, Friedrich, Aachen, GERMANY, FEDERAL REPUBLIC OF <b>Kirchmeyer, Stephan</b> , Leverkusen, GERMANY, FEDERAL REPUBLIC OF
PI	US 2002173579 A1 20021121
AI	US 2002-93219 A1 20020307 (10)
PRAI	DE 2001-111790 20010312
DT	Utility
FS	APPLICATION
LN.CNT	574
INCL	INCLM: 524/502.000
NCL	NCLM: 524/502.000
IC	[7]
	ICM: C08L001-00
	ICS: C08K003-00; C08J003-00

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L2 ANSWER 6 OF 6 USPATFULL

Full Text	Citing References
AN	2002:149291 USPATFULL
TI	<b>Polythiophenes</b>
IN	<b>Kirchmeyer, Stephan</b> , Leverkusen, GERMANY, FEDERAL REPUBLIC OF Wussow, Klaus, Netphen, GERMANY, FEDERAL REPUBLIC OF Jonas, Friedrich, Aachen, GERMANY, FEDERAL REPUBLIC OF Elschner, Andreas, Mulheim, GERMANY, FEDERAL REPUBLIC OF
PI	US 2002077450 A1 20020620
AI	US 2001-988858 A1 20011121 (9)
PRAI	DE 2000-10058116 20001122
DT	Utility
FS	APPLICATION
LN.CNT	489
INCL	INCLM: 528/373.000
NCL	NCLM: 528/373.000
IC	[7]
	ICM: C08G075-00

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=> s **polythiophene#**  
L3 4251 POLYTHIOPHENE#

=> s 13 and oxidant#  
L4 451 L3 AND OXIDANT#

=> s 14 and phase transfer catalyst#  
L5 3 L4 AND PHASE TRANSFER CATALYST#

=> d 15 1-3

L5 ANSWER 1 OF 3 EUROPATFULL COPYRIGHT 2003 WILA

Full Text
PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET
AN 295084 EUROPATFULL ED 20001001 EW 198850 FS OS STA B
TIEN Novel copolymers and electroactive polymers derived from same.

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 295084 EUROPATFULL ED 20001001 EW 198850 FS OS STA B

TIEN Novel copolymers and electroactive polymers derived from same.

TIDE Copolymere und daraus abgeleitete elektroaktive Polymere.  
TIFR Copolymères et polymères électroactifs qui en dérivent.  
IN Shikatani, Yutaka, 2-228, Kosugi-cho Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Kuroda, Nobuyuki, 185-2, Shirahatakami-cho Kanagawa-ku, Yokohama-shi  
Kanagawa-ken, JP;  
Shimo, Yoshiyuki, 155-72, Honmokuhsato-cho Naka-ku, Yokohama-shi  
Kanagawa-ken, JP;  
Kataoka, Naoki, 17-25, Shinjonaka-machi Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Matsuura, Kazuo, 2-22-18, Higashiyukigaya, Ohta-ku Tokyo, JP;  
Kawamata, Etsuo, 2-228, Kosugi-cho Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Kobayashi, Hiroshi, 155-72, Honmokuhsato-cho Naka-ku, Yokohama-shi  
Kanagawa-ken, JP  
PA NIPPON OIL CO. LTD., 3-12, 1-chome Nishi-Shinbashi, Minato-ku Tokyo 105,  
JP  
SO Wila-EPZ-1988-H50-T1  
DS R DE; R FR; R GB  
PIT EPA2 EUROPAEISCHE PATENTANMELDUNG  
PI EP 295084 A2 19881214  
OD 19881214  
AI EP 1988-305237 19880608  
PRAI JP 1987-143267 19870610  
JP 1987-153427 19870622  
JP 1987-153429 19870622  
IC ICM C08G073-06  
ICS C08G061-12 H01B001-12

GRANTED PATENT - ERTEILTES PATENT - BREVET DELIVRE

AN 295084 EUROPATFULL UP 20010906 EW 199438 FS PS STA B  
TIFN Novel copolymers and electroactive polymers derived from same.  
TIDE Copolymere und daraus abgeleitete elektroaktive Polymere.  
TIFR Copolymères et polymères électroactifs qui en dérivent.  
IN Shikatani, Yutaka, 2-228, Kosugi-cho Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Kuroda, Nobuyuki, 185-2, Shirahatakami-cho Kanagawa-ku, Yokohama-shi  
Kanagawa-ken, JP;  
Shimo, Yoshiyuki, 155-72, Honmokuhsato-cho Naka-ku, Yokohama-shi  
Kanagawa-ken, JP;  
Kataoka, Naoki, 17-25, Shinjonaka-machi Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Matsuura, Kazuo, 2-22-18, Higashiyukigaya, Ohta-ku Tokyo, JP;  
Kawamata, Etsuo, 2-228, Kosugi-cho Nakahara-ku, Kawasaki-shi  
Kanagawa-ken, JP;  
Kobayashi, Hiroshi, 155-72, Honmokuhsato-cho Naka-ku, Yokohama-shi  
Kanagawa-ken, JP  
PA NIPPON OIL CO. LTD., 3-12, 1-chome Nishi-Shinbashi, Minato-ku Tokyo 105,  
JP  
SO Wila-EPS-1994-H38-T1  
DS R DE; R FR; R GB  
PIT EPB1 EUROPAEISCHE PATENTSCHEFT  
PI EP 295084 B1 19940921  
OD 19881214  
AI EP 1988-305237 19880608  
PRAI JP 1987-143267 19870610  
JP 1987-153427 19870622  
JP 1987-153429 19870622  
REP GB 2130594 A US 4505844 A  
US 4548738 A US 4631323 A  
REN PATENT ABSTRACTS OF JAPAN, vol. 10, no. 182 (C-356) (2238), 25th June  
1986; &  
JP-A-6128524 SYNTHETIC METALS, vol. 10, 1985, pages 281-292; S. JENEKHE  
et al.: "Electrically conducting complexes of poly(3,6-N-Methylcarbazoyl

methylene)"  
IC ICM C08G073-06  
ICS C08G061-12 H01B001-12 C08G016-02 H01M004-60

L5 ANSWER 2 OF 3 USPATFULL

Full Text	Citing References
-----------	-------------------

AN 2002:149291 USPATFULL

TI **Polythiophenes**

IN Kirchmeyer, Stephan, Leverkusen, GERMANY, FEDERAL REPUBLIC OF  
Wussow, Klaus, Netphen, GERMANY, FEDERAL REPUBLIC OF  
Jonas, Friedrich, Aachen, GERMANY, FEDERAL REPUBLIC OF  
Eltschner, Andreas, Mulheim, GERMANY, FEDERAL REPUBLIC OF

PI	US 2002077450	A1	20020620
AI	US 2001-988858	A1	20011121 (9)
PRAI	DE 2000-10058116		20001122

DT Utility

FS APPLICATION

LN.CNT 489

INCL INCLM: 528/373.000

NCL NCLM: 528/373.000

IC [7]

ICM: C08G075-00

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L5 ANSWER 3 OF 3 USPATFULL

Full Text	Citing References
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AN 90:67720 USPATFULL

TI Novel copolymers and electroactive polymers derived from same

IN Shikatani, Yutaka, Kawasaki, Japan  
Kuroda, Hobuyuki, Yokohama, Japan  
Kataoka, Naoki, Kawasaki, Japan  
Shimo, Yoshiyuki, Yokohama, Japan  
Matsuura, Kazuo, Tokyo, Japan  
Kawamata, Etsuo, Kawasaki, Japan  
Kobayashi, Hiroshi, Yokohama, Japan

PA Nippon Oil Company, Limited, Japan (non-U.S. corporation)

PI US 4952667 19900828

AI US 1988-204083 19880608 (7)

PRAI JP 1987-153429 19870622

JP 1987-153427 19870622

JP 1987-143267 19871006

DT Utility

FS Granted

LN.CNT 482

INCL INCLM: 528/230.000

INCLS: 528/247.000; 528/248.000; 528/249.000; 528/266.000; 528/269.000;  
252/500.000; 252/511.000

NCL NCLM: 528/230.000

NCLS: 252/500.000; 252/511.000; 528/247.000; 528/248.000; 528/249.000;  
528/266.000; 528/269.000

IC [5]

ICM: C08G010-02

EXF 528/230; 528/247; 528/248; 528/249; 528/266; 528/269; 252/500; 252/511

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=> s 14 and sulfonic acid

L6 211 L4 AND SULFONIC ACID

=> s 16 and (phase transfer catalyst# or quaternary ammonium salt#)

L7 7 L6 AND (PHASE TRANSFER CATALYST# OR QUATERNARY AMMONIUM SALT#)

=> d 17 1-7

L7 ANSWER 1 OF 7 EUROPATFULL COPYRIGHT 2003 WILA

Full  
Text

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 1202115 EUROPATFULL ED 20020507 EW 200218 FS OS  
 TIEN Silver halide photographic material comprising a permanent conductive  
 subbing layer and a scratch-resistant backing layer.  
 TIDE Photographisches Silberhalogenidmaterial mit einer dauerhaften  
 elektrisch leitenden Haftvermittlungsschicht und einer kratzfesten  
 Rueckseitenschicht.  
 TIFR Materiau photographique a l'halogenure d'argent comprenant une couche  
 adhesive a electroconductivite permanente et une couche dorsale  
 resistant aux rayures.  
 IN Viaene, Kris Agfa Gevaert, Corporate IP Department 3800 Septestraat 27,  
 2640 Mortsel, BE;  
 Van Thillo, Etienne c/o Agfa-Gevaert, Corporate IP Department 3800  
 Septestraat 27, 2640 Mortsel, BE;  
 Andries, Hartwig c/o Agfa-Gevaert, Corporate IP Department 3800  
 Septestraat 27, 2640 Mortsel, BE  
 PA AGFA-GEVAERT, Septestraat 27, 2640 Mortsel, BE  
 SO Wila-EPZ-2002-H18-T2a  
 DS R AT; R BE; R CH; R CY; R DE; R DK; R ES; R FI; R FR; R GB; R GR; R IE;  
 R IT; R LI; R LU; R MC; R NL; R PT; R SE; R TR; R AL; R LT; R LV; R MK;  
 R RO; R SI  
 PIT EPAL EUROPAEISCHE PATENTANMELDUNG  
 PI EP 1202115 A1 20020502  
 OD 20020502  
 AI EP 2001-511 20010928  
 PRAI EP 2000-203479 20001005  
 IC ICM G03C001-91  
 ICS G03C001-93 G03C001-76

L7 ANSWER 2 OF 7 PCTFULL COPYRIGHT 2003 Univentio

Full  
Text

AN 2002094910 PCTFULL ED 20021210 EW 200248  
 TIEN ELECTROLUMINESCENT POLYMERS AND USE THEREOF IN LIGHT-EMITTING DEVICES  
 TIFR POLYMERES ELECTROLUMINESCENTS ET LEUR UTILISATION DANS DES DISPOSITIFS  
 EMETTANT DE LA LUMIERE  
 IN PEI, Qibing  
 PA SRI INTERNATIONAL  
 AG REED, Dianne, E.  
 LAF English  
 LA English  
 DT Patent  
 PI WO 2002094910 A1 20021128  
 DS AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ DE DK DM DZ  
 EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE KG KP KR KZ LC LK LR  
 LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ OM PH PL PT RO RU SD SE SG SI  
 SK SL TJ TM TN TR TT TZ UA UG UZ VN YU ZA ZM ZW GH GM KE LS MW MZ SD SL  
 SZ T2 UG ZM ZW AM AZ BY KG KZ MD RU TJ TM AT BE CH CY DE DK ES FI FR GB  
 GR IE IT LU MC NL PT SE TR BF BJ CF CG CI CM GA GN GQ GW ML MR NE SN TD  
 TG  
 AI WO 2002-US16180 A 20020522  
 PRAI US 2001-09/864,704 20010523  
 ICM C08G073-00

L7 ANSWER 3 OF 7 USPATFULL

Full  
Text

Citing  
References

AN 2003:18086 USPATFULL  
 TI Electroluminescent polymers and use thereof in light-emitting devices  
 IN Pei, Qibing, Fremont, CA, UNITED STATES  
 PI US 2003013843 A1 20030116  
 AI US 2002-153229 A1 20020521 (10)  
 RLI Continuation-in-part of Ser. No. US 2001-864704, filed on 23 May 2001,  
 PENDING  
 DT Utility  
 FS APPLICATION  
 LN.CNT 1600  
 INCL INCLM: 528/422.000  
 NCL NCLM: 528/422.000  
 IC [7]  
 ICM: C08G073-00

L7 ANSWER 4 OF 7 USPATFULL

Full Text	Citing References
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AN 2002:338181 USPATFULL  
 TI Conjugated electroluminescent polymers and associated methods of preparation and use  
 IN Pei, Qibing, Fremont, CA, UNITED STATES  
 PI US 2002193551 A1 20021219  
 AI US 2001-864704 A1 20010523 (9)  
 DT Utility  
 FS APPLICATION  
 LN.CNT 1529  
 INCL INCLM: 528/086.000  
 INCLS: 528/211.000; 528/422.000; 528/423.000; 528/486.000; 525/242.000; 544/001.000; 428/690.000; 428/917.000  
 NCL NCLM: 528/086.000  
 NCLS: 528/211.000; 528/422.000; 528/423.000; 528/486.000; 525/242.000; 544/001.000; 428/690.000; 428/917.000  
 IC [7]  
 ICM: C08G073-00  
 CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L7 ANSWER 5 OF 7 USPATFULL

Full Text	Citing References
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AN 2002:227861 USPATFULL  
 TI Silver halide photographic material comprising a permanent conductive subbing layer and a scratch-resistant backing layer  
 IN Viaene, Kris, Bonheiden, BELGIUM  
 Thillo, Etienne Van, Essen, BELGIUM  
 Andries, Hartwig, Rupelmonde, BELGIUM  
 PI US 2002123013 A1 20020905  
 AI US 2001-968292 A1 20011001 (9)  
 PRAI EP 2000-203479 20001005  
 US 2000-243475P 20001027 (60)  
 DT Utility  
 FS APPLICATION  
 LN.CNT 1433  
 INCL INCLM: 430/522.000  
 INCLS: 430/510.000; 430/517.000; 430/527.000; 430/529.000; 430/530.000; 430/961.000  
 NCL NCLM: 430/522.000  
 NCLS: 430/510.000; 430/517.000; 430/527.000; 430/529.000; 430/530.000; 430/961.000  
 IC [7]  
 ICM: G03C001-825  
 ICS: G03C001-83; G03C001-85; G03C001-89; G03C001-93  
 CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L7 ANSWER 6 OF 7 USPATFULL

Full Text	Citing References
-----------	-------------------

AN 2002:149291 USPATFULL

TI **Polythiophenes**

IN Kirchmeyer, Stephan, Leverkusen, GERMANY, FEDERAL REPUBLIC OF  
Wussow, Klaus, Netphen, GERMANY, FEDERAL REPUBLIC OF  
Jonas, Friedrich, Aachen, GERMANY, FEDERAL REPUBLIC OF  
Elschner, Andreas, Mulheim, GERMANY, FEDERAL REPUBLIC OF

PI US 2002077450 A1 20020620

AI US 2001-988858 A1 20011121 (9)

PRAI DE 2000-10058116 20001122

DT Utility

FS APPLICATION

LN.CNT 489

INCL INCLM: 528/373.000

NCL NCLM: 528/373.000

IC [7]

ICM: C08G075-00

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L7 ANSWER 7 OF 7 USPATFULL

Full Text	Citing References
-----------	-------------------

AN 94:3835 USPATFULL

TI Method of processing neutral polyanilines in solvent and solvent mixtures

IN Han, Chien-Chung, Madison, NJ, United States

Shacklette, Lawrence W., Maplewood, NJ, United States

Elsenbaumer, Ronald, Morristownship, Morris County, NJ, United States

PA Allied Signal Inc., Morristown, NJ, United States (U.S. corporation)

PI US 5278213 19940111

AI US 1991-689420 19910422 (7)

DT Utility

FS Granted

LN.CNT 1538

INCL INCLM: 524/233.000

INCLS: 528/422.000

NCL NCLM: 524/233.000

NCLS: 528/422.000

IC [5]

ICM: C08K005-20

EXF 524/233; 528/422

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

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